## [METHOD OF MANUFACTURING A REFLECTOR]

## **Abstract of Disclosure**

A method of manufacturing a bumpy reflector utilizes a process of forming thin film transistors to fabricate bumps simultaneously, thereby reducing the frequency of using photo masks. Additionally, by varying positions, numbers, and widths of the deposition layers, the bumps of different heights and widths are formed, and therefore, the bumpy reflector has a better effect on reflecting light beams. Furthermore, a photosensitive organic layer with a molten characteristic is used to replace a passivation layer and a photoresist layer, which can simplify the fabrication processes of manufacturing a reflector. Consequently, an LCD of good quality and low production cost is manufactured.

## Figures